



(11)

EP 1 335 402 B1

(12)

EUROPEAN PATENT SPECIFICATION

(45) Date of publication and mention
of the grant of the patent:
06.07.2016 Bulletin 2016/27

(51) Int Cl.:
H01J 37/05 ^(2006.01) **H01J 37/26** ^(2006.01)

(21) Application number: **03250799.8**

(22) Date of filing: **07.02.2003**

(54) **Wien filter and electron microscope using same**

Wienfilter und damit ausgerüstetem Elektronenmikroskop

Filtre de Wien et microscope électronique muni d'un tel filtre

(84) Designated Contracting States:
DE NL

(30) Priority: **08.02.2002 JP 2002031993**

(43) Date of publication of application:
13.08.2003 Bulletin 2003/33

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- **M. HAIDER, W. BERNHARDT, H. ROSE: "Design and test of an electric and magnetic dodecapole lens" OPTIK, vol. 63, no. 1, 1982, pages 9-23, XP008051532 Stuttgart**
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Description

BACKGROUND OF THE INVENTION

1. Field of the Invention

[0001] The present invention relates to a Wien filter ($E \times B$ filter) used in an energy filter for use in an electron microscope, mass filter, spin rotator, monochrometer, energy analyzer, or the like. The invention also relates to an electron microscope using such a Wien filter.

2. Description of the Related Art

[0002] Accelerated charged particles such as electrons are deflected toward positive poles with respect to an electric field. With respect to a magnetic field, the particles are deflected perpendicular to the direction of travel of the particles and to the magnetic field. A Wien filter makes use of this nature and uses electric and magnetic fields that are placed perpendicular to each other within a plane perpendicular to the direction of travel of the charged-particle beam. The beam is made to move straight in a certain direction.

[0003] The condition under which a charged-particle beam goes straight through a Wien filter is known as the Wien condition and given by

$$E_1 = v B_1$$

where E_1 is the first-order component (dipole component) of the electric field, B_1 is the first-order component (dipole component) of the magnetic field, and v is the velocity of the charged particles.

[0004] It has been considered that the Wien condition can be satisfied within the inner area excluding the vicinities (known as fringing fields) of the entrance and exit for the beam, for the following reason. Where the electrodes and magnetic pole pieces are different in geometry, the electric and magnetic fields are different in distribution and, therefore, the Wien condition holds in some locations but does not in other locations. The magnetic pole pieces may be hereinafter often referred to as magnetic poles or simply as poles.

[0005] A Wien filter in which electrodes and magnetic polepieces are identical in geometry has been proposed by Tang (Optik, 74, No. 2 (1986), 51-56, AberrationAnalysisofaCrossed-FieldAnalyzer, Tian-Tong Tang). This is an octopole filter, and the electrodes and magnetic polepieces are identical in geometry. Therefore, the problem that the fringing fields do not satisfy the Wien condition can be circumvented. Hence, a Wien filter having theoretically expected performance can be accomplished:

[0006] However, when the Tang's filter is put into practical use, a drawback occurs. The filter has eight poles that are used as individual electrodes and magnetic pole pieces. These electrodes and magnetic pole pieces create their respective dipole and quadrupole components. In consequence, a number of power supplies are necessary. In practice, Wien filters are often used floating on high voltages to provide large dispersion. It is not practical to place a number of power supplies in locations at high electric potentials. For these reasons, the Tang's filter has not been put into practical use.

[0007] On the other hand, we have proposed a practical octopole filter (Japanese Patent No. 3040245), which is shown in Fig. 9, (a) and (b). This filter has greater poles P_1 , P_3 , P_5 , and P_7 and smaller poles P_2 , P_4 , P_6 , and P_8 , i.e., eight poles in total. The poles P_2 , P_3 and P_4 together form a magnetic pole pair via a coil C1. Similarly, the poles P_6 , P_7 and P_8 together form a magnetic pole pair via a coil C2. The poles P_2 , P_1 , and P_8 together form an electrode pair. Similarly, the poles P_4 , P_5 and P_6 together form an electrode pair.

[0008] The poles P_2 , P_1 , and P_8 are fabricated integrally. Similarly, the poles P_4 , P_5 , and P_6 are fabricated integrally. The poles P_2 , P_4 , P_6 , and P_8 are bent at their intermediate locations to facilitate winding the coil C1 between the poles P_2 and P_4 across the pole P_3 and winding the coil C2 between the poles P_6 and P_8 across the pole P_7 .

[0009] Because of this arrangement of the electrodes and magnetic pole pieces, the Wien filter can be operated with only three input terminals and three power supplies. One of the three input terminals is used to supply current into the coils C1 and C2 at ground potential. Another input terminal is used for a positive voltage. The remaining input terminal is used for a negative potential. It is known that stigmatic focusing can be achieved under the condition

$$\frac{E_2}{E_1} - \frac{B_2}{B_1} = -\frac{1}{4} R_0 \quad (1)$$

where E_2 is the quadrupole component of the electric field, B_2 is the quadrupole component of the magnetic field, and R_0 is the cyclotron radius of the charged particles where the magnetic field exists alone and given by

$$R_0 = \frac{mv^2}{eE_1} \quad (2)$$

where v is the velocity of the charged particles, m is the mass of the charged particles, and e is the charge of the charged particles.

[0010] A quadrupole electric field for achieving stigmatic focusing by satisfying the above-described condition may be realized also by varying the ratio of the absolute values of voltages applied to the poles P_2 , P_1 , P_8 and to the poles P_4 , P_5 , and P_6 , but this is not strictly true. Therefore, it is better to fulfill the condition by producing a quadrupole electric field using four poles P_1 , P_3 , P_5 , and P_7 (i.e., with addition of the poles P_3 and P_7).

[0011] These circumstances are described in detail in J. Electron Microsc., 45: 417-427 (1996), Simulation of Electron Trajectories of Wien Filter for High-Resolution EELS Installed in TEM (K. Tsuno and J. Rouse).

[0012] In the Wien filter (octopole filter) described in the above-cited Japanese patent No. 3040245, the electrodes are exactly identical in geometry with the magnetic polepieces. Therefore, charged particles are not deflected at the fringes. In practice, the instrument has been put into practical use as a monochrometer, and has excellent ease of use. However, it has still been difficult to reduce the aberration down to zero. Generally, a Wien filter has a considerably large amount of second-order aberration. Where it is used as a monochrometer, the size of the charged-particle beam going out of the filter is greater than that of the beam yet to enter the filter.

[0013] With respect to the second-order aberration of the Wien filter, H. Rose has already shown a condition capable of making it zero (Optik, 77, No. 1 (1987) 26-34, The retarding Wien filter as a high-performance imaging filter, H. Rose).

[0014] This condition is given by Eqs. (3) to (9).

$$e_2 = -1 \quad (3)$$

$$b_2 = -\frac{3}{4} \quad (4)$$

$$e_3 - b_3 = \frac{3}{8} \quad (5)$$

where

$$e_2 = \left(\frac{E_2}{E_1} \right) R_0 \quad (6)$$

$$b_2 = \left(\frac{B_2}{B_1} \right) R_0 \quad (7)$$

$$e_3 = \left(\frac{E_3}{E_1} \right) R_0^2 \quad (8)$$

$$b_3 = \left(\frac{B_3}{B_1} \right) R_0^2 \quad (9)$$

where E_1 and B_1 are the dipole components of the electric and magnetic fields, respectively, E_2 and B_2 are quadrupole components of the fields, respectively, E_3 is the high-order inhomogeneous component of the electric field E_1 , B_3 is the high-order inhomogeneous component of the magnetic field B_1 .

[0015] Among these conditions, e_2 and b_2 can be achieved relatively easily, for the following reason. The condition for achieving stigmatic focusing is expressed by Eq. (1) and given by

$$\frac{E_2}{E_1} - \frac{B_2}{B_1} = e_2 - b_2 = -\frac{1}{4} R_0$$

Therefore, it suffices to determine the relation between e_2 and b_2 so as to satisfy this condition.

[0016] With respect to e_3 and b_3 , we have made a simulation to know the value of the high-order inhomogeneous component E_3 of the electric field in the above-described octupole filter. In this simulation, a numerical computation method known as boundary element method (BEM) was used. In particular, geometric parameters of the Wien filter (i.e., radius R of the cylindrical portion within the XY-plane perpendicular to the direction of travel of the charged particles, angular positions of the poles, polar interval, and length L_0 taken in the direction of the Z-axis) were calculated. Various conditions including voltages for producing the dipole and quadrupole fields were established. The distributions of the potentials ϕ of the dipole and quadrupole fields and of the hexapole field parasitic to the dipole field were calculated. The dipole, quadrupole, and hexapole fields are respectively given by (dipole field):

$$\phi_1 = \phi_0 - E_1 x + (1/8) E_1'' (x^3 + y^2 x) + \dots \quad (10)$$

where

$$E_1'' = \frac{\partial^2 E_1}{\partial z^2}$$

(quadrupole field):

$$\phi_2 = -\{E_2 - (1/12) E_2'' (x^2 + y^2)\} (x^2 - y^2) + \dots \quad (11)$$

(hexapole field):

$$\phi_3 = -E_3 (x^3 + 3xy^2) + \dots \quad (12)$$

Therefore, the electric field potential ϕ on the x-axis, for example, is given by

$$\phi = \phi_1 + \phi_2 + \phi_3 + \dots$$

$$= \phi_0 - E_1 x + E_2 x^2 - (1/8) E_1'' x^3 - E_3 x^3 + (1/12) E_2'' x^4 + \dots \quad (13)$$

[0017] In the foregoing, it is assumed that the radius R of the cylindrical portion is 5 mm, L = 40 mm, and accelerating voltage is 2.5 kV. Furthermore, the dipole electric field = 1651.1734 V, quadrupole electric field = 280.7162 V, dipole magnetic field = 44.3101 AT, and quadrupole magnetic field = 6.5412 AT.

[0018] Fig. 8 shows the distribution of the high-order inhomogeneous component E_3 along the optical axis where a dipole electric field of 1 V is applied. As can be seen from this graph, the high-order inhomogeneous component E_3 has a high value of 12000 V/m³ in the fringing fields. In Fig. 8(a), the horizontal axis indicates the direction of travel (Z-axis direction) of charged particles through an octopole Wien filter shown in Fig. 8(b). The vertical axis indicates the high-order inhomogeneous component E_3 of the electric field.

[0019] It is possible to reduce the high-order inhomogeneous component E_3 close to zero outside the fringing fields by adjusting the angular positions of the poles. However, the component stays at large values in the fringing fields and cannot be reduced to a small value. The same situation applies to the high-order inhomogeneous component B_3 of the magnetic field. Therefore, the conventional Wien filter has the problem that the second-order aberration cannot be reduced.

[0020] M. Haider, W. Bernhardt and H. Rose, "Design and test of an electric and magnetic dodecapole lens", Optik, 63, No. 1 (1982) PP. 9-23, relates to an electric and magnetic 12-pole lens for correcting electron-optical aberrations.

SUMMARY OF THE INVENTION

[0021] The present invention addresses the foregoing problem. It would be desirable to provide a Wien filter in which a less amount of secondary aberration is produced than conventional.

[0022] According to the present invention, there is provided a Wien filter as specified in claim 1.

[0023] Furthermore, the present invention provides an electron microscope designed to cause an electron beam produced from an electron gun to hit a sample via a Wien filter that passes only electrons having a certain energy, as specified in claim 4.

[0024] Other objects and features of the invention will appear in the course of the description thereof, which follows.

BRIEF DESCRIPTION OF THE DRAWINGS

[0025]

Fig. 1 is a cross-sectional view taken along the XY-plane perpendicular to the optical axis of a Wien filter according to a first embodiment of the present invention, it being noted that Fig. 1 is also a cross-sectional view taken along line 1-1 of Fig. 2;

Fig. 2 is a cross-sectional view taken along the XZ-plane of the Wien filter shown in Fig. 1, and in which the Z-axis is coincident with the optical axis, Fig. 2 being also a cross-sectional view taken along line 2-2 of Fig. 1;

Fig. 3 is a view similar to Fig. 1, but illustrating the magnitudes of electric potentials applied to the various poles of the Wien filter shown in Fig. 1;

Fig. 4 is a view similar to Fig. 1, but illustrating the magnitudes or values of magnetomotive forces (in ampere-turns) applied to the various poles of the Wien filter shown in Fig. 1;

Fig. 5 is a schematic diagram of a Wien filter according to a second embodiment of the invention;

Fig. 6 is a graph showing the intensity distribution of the high-order inhomogeneous component E_3 of an electric field produced in a Wien filter according to an embodiment of the invention, the distribution being taken along the optical axis;

Fig. 7, (a) and (b), shows the configuration of an electron microscope incorporating a Wien filter according to the invention;

(a) shows an embodiment in which the Wien filter according to the invention is placed between an FEG and an accelerator and

(b) shows an embodiment in which the Wien filter is placed behind the accelerator;

Fig. 8 is a diagram showing the distribution of a high-order inhomogeneous component E_3 produced when a dipole electric field of 1 V is applied, the distribution being taken along the optical axis; and

Fig. 9, (a) and (b), shows an example of an octopole filter.

DETAILED DESCRIPTION OF THE INVENTION

[0026] Wien filters according to embodiments of the present invention are hereinafter described by referring to Figs. 1-5.

[0027] Referring to Figs. 1-4, there is shown a Wien filter according to one embodiment of the invention. Generally, this filter has an optical axis O parallel to the Z -axis direction, and produces at least a dipole electric field E_1 in the X -axis direction and a dipole magnetic field B_1 in the Y -axis direction. The filter is fitted with 12 poles P_1 to P_{12} extending substantially parallel to the optical axis O . The front ends P_1' to P_{12}' of the poles P_1 to P_{12} which face the optical axis O have a 12-fold rotational symmetry about the optical axis O within the XY -plane. The X -, Y -, and Z -axes are mutually orthogonal Cartesian axes. The 12 poles P_1 to P_{12} are made of a magnetic material such as iron, nickel, or Permalloy. The Wien filter is described in further detail below.

[0028] As shown in Figs. 1 and 2, the Wien filter according to this embodiment has the 12 poles P_1 to P_{12} extending parallel to the optical axis O to create an electromagnetic field of a desired distribution inside a cylindrical space 21 through which electrons, i.e., charged particles, pass. The center axis of the space 21 is coincident with the optical axis O .

[0029] As shown in Fig. 1, the 12 poles P_1 to P_{12} have front ends P_1' and P_{12}' , respectively, which face the optical axis O and have a 12-fold rotational symmetry about the optical axis O within the XY -plane. More specifically, the front ends P_1' to P_{12}' of the poles P_1 to P_{12} are all identical in shape and dimensions. The front ends P_1' to P_{12}' are regularly spaced from each other. Therefore, the angle θ_0 made between the circumferentially successively adjacent center positions of the gaps G_1 to G_{12} between the front ends or between the circumferentially successively adjacent center positions of the front ends P_1' to P_{12}' is 30° . The angle from the circumferentially center position of each of the gaps G_1 to G_{12} between the front ends to a respective one of the circumferentially center positions of the front ends P_1' to P_{12}' is 15° . For example, in Fig. 1, the angles from the positive side of the X -axis (that agrees with a straight line drawn from the center O to the circumferentially midway point of the gap G_{12} in Fig. 1) to the circumferentially center positions of the poles P_1 and P_{12} are $\pm 15^\circ$. The angles from the positive side of the X -axis to the circumferentially center positions of the poles P_6 and P_{17} are $\pm 165^\circ$. Also in Fig. 1, the angles from the positive side of the Y -axis to the circumferentially center positions of the poles P_4 and P_3 are $\pm 15^\circ$. The angles from the positive side of the Y -axis to the circumferentially center positions of the poles P_9 and P_{10} are $\pm 165^\circ$.

[0030] The adjacent ones of the front ends P_1' to P_{12}' form gaps G_1 to G_{12} , respectively, which are identical in shape and dimensions. Preferably, the width (i.e., the space between adjacent poles P_i and P_{i+1}) of each of the gaps G_1 to G_{12} increases with the radius from the center O as shown.

[0031] The shape and dimensions of the front ends P_1' to P_{12}' can be analogous and close to those of a Wien filter according to an embodiment described below.

[0032] The radial length or width of each of the front ends P_1' to P_{12}' of the poles P_1 to P_{12} can be made comparable to the diameter $2R_0$ of the cylindrical space 21, for example.

[0033] Each of the poles P_1 to P_{12} can be bent in an appropriate direction (e.g., to be parallel to the Y -axis) at a distance of W_0 from the foremost end facing the optical axis or cylindrical space 21. The distance W_0 is approximately equal to the diameter $2R_0$ of the cylindrical space 21. In particular, the pole P_4 , for example, has a side surface P_{4a} extending in the direction of the radius of R_0 inside a location that is at a distance of W_0 from the foremost end and a side surface P_{4b} extending in the Y -axis direction outside this location at a distance of W_0 as indicated by the phantom lines in Fig. 1.

[0034] Because of this structure, where a magnetomotive force is applied to each of the poles P_1 to P_{12} , a coil can be easily wound to each pole.

[0035] Fig. 3 shows electric potentials applied to the poles P_1 to P_{12} to produce the dipole electric field E_1 and quadrupole electric field E_2 inside the cylindrical space 21 whose center axis is coincident with the optical axis O . As shown in this figure, within the XY -plane perpendicular to the optical axis O , a first potential V_1 is applied to the four poles P_1 , P_{12} , P_6 , and P_7 whose front ends are substantially in the X -axis direction. The first potential V_1 is also applied to the four poles P_2 , P_{11} , P_5 , and P_8 whose front ends are at about 45° to the X -axis.

[0036] More specifically, the positive potential V_1 is applied to the poles P_1 and P_{12} extending at angles of $\pm 15^\circ$ to the positive side of the X -axis and to the poles P_2 and P_{11} extending at angles of $\pm 165^\circ$ to the positive side of the X -axis. The negative potential $-V_1$ is applied to the poles P_6 and P_7 extending at angles of $\pm 165^\circ$ to the positive side of the X -axis and to the poles P_5 and P_8 extending at angles of $\pm 135^\circ$ to the positive side of the X -axis.

[0037] To superimpose the quadrupole electric field E_2 on the dipole magnetic field E_1 , a second electric potential of V_2 is applied to the four poles P_1 , P_{12} , P_6 , and P_7 whose front ends are substantially parallel to the X -axis and also to the four poles P_3 , P_4 , P_9 , and P_{10} whose front ends are substantially parallel to the Y -axis. More specifically, the potential V_2 applied to the poles P_1 , P_{12} , P_6 , and P_7 is positive, while the potential V_2 applied to the poles P_3 , P_4 , P_9 , and P_{10} is negative. As mentioned previously, the poles P_4 and P_3 extend at angles of $\pm 15^\circ$ to the positive side of the Y -axis, and the poles P_9 and P_{10} extend at angles of $\pm 165^\circ$ to it.

[0038] Fig. 4 shows magnetic potentials or magnetomotive forces applied to the poles P_1 and P_{12} to produce dipole magnetic field B_1 and quadrupole magnetic field B_2 in the cylindrical space 21. More specifically, as shown in this figure, a first magnetomotive force of NI_1 (in ampere-turns) is applied to the four poles P_3 , P_4 , P_9 , and P_{10} whose front ends are substantially parallel to the Y-axis (more specifically at angles of 75° , 105° , 255° , and 285° , respectively, to the positive side of the X-axis) and to the four poles P_2 , P_5 , P_8 , and P_{11} whose front ends are at an angle of 45° to the X-axis.

[0039] To superimpose the quadrupole magnetic field B_2 on the dipole magnetic field B_1 , a second magnetomotive force of NI_2 (in ampere-turns) is applied to the four poles P_2 , P_5 , P_8 , and P_{11} whose front ends are at an angle of about 45° to the X-axis.

[0040] In the above-described configuration, high-order inhomogeneous components E_3 and B_3 of the dipole electric field E_1 and dipole magnetic field B_1 , respectively, in the fringing fields can be made quite small.

[0041] More specifically, in the configuration described above, the gaps G_1 to G_{12} formed between the poles P_1 and P_{12} and the side surfaces of the poles P_1 to P_{12} facing the gaps G_1 to G_{12} are arranged with a 12-fold rotational symmetry. On the other hand, the high-order inhomogeneous components E_3 and B_3 of the dipole electric field E_1 and dipole magnetic field B_1 , respectively, originate from the side surfaces of the poles P_1 and P_{12} that face the gaps G_1 and G_{12} . Accordingly, in this embodiment, since the side surfaces of the poles P_1 and P_{12} facing the gaps are arranged with a 12-fold symmetry, the high-order inhomogeneous components E_3 and B_3 cancel out, leaving behind only a small total value. This theory applies especially well to the case of the high-order inhomogeneous components E_3 and B_3 in the fringing fields.

[0042] Therefore, in the Wien filter of this embodiment, the high-order inhomogeneous components E_3 and B_3 can be made quite small. Hence, the values of the components E_3 and B_3 can be adjusted to satisfy the Rose's condition maximally. As a result, aberration in the electron beam in the Wien filter can be reduced.

[0043] Referring next to Fig. 5, there is shown a Wien filter according to a second embodiment of the invention. The 12 poles P_1 to P_{12} of this filter are similar in geometry and dimensions to their respective counterparts of the instrument according to the first embodiment already described. Potentials V_1 and V_2 are applied to these poles P_1 to P_{12} to produce the dipole electric field E_1 and quadrupole electric field E_2 as shown in Fig. 3 in the same way as in the first embodiment. In addition, a magnetomotive force NI_1 is applied to the poles P_2 - P_5 and to P_8 - P_{11} to produce dipole magnetic field B_1 as shown in Fig. 5 in the same way as in the first embodiment.

[0044] On the other hand, a magnetomotive force NI_2 acting as a third magnetomotive force having a positive value is applied to the three poles P_1 to P_3 whose front ends are located within the first quadrant of the XY-coordinate system whose origin lies at the optical axis O. A magnetomotive force $-NI_2$ acting as the third magnetomotive force having a negative value is applied to the three poles P_4 to P_6 located within the second quadrant. A magnetomotive force NI_2 acting as the third magnetomotive force having a positive value is applied to the three poles P_7 to P_9 located within the third quadrant. A magnetomotive force $-NI_2$ acting as the third magnetomotive force having a negative value is applied to the three poles P_{10} to P_{12} located within the fourth quadrant. As already understood, the second and third magnetomotive forces are equal in this embodiment.

[0045] This second embodiment yields advantages similar to those derived by the first embodiment. That is, high-order inhomogeneous components E_3 and B_3 of the dipole electric field E_1 and dipole magnetic field B_1 , respectively, in the fringing fields can be made infinitesimal. Aberration in the energy filter can be reduced by adjusting these components to desired values.

[0046] In the first and second embodiments described above, the gaps G_1 to G_{12} between the front ends of the poles P_1 to P_{12} increase in going along the radius. The gaps may also be regularly spaced from each other in a radial direction (i.e., the walls of the poles are parallel).

[0047] The Wien filter of this embodiment shown in Fig. 1 had the following geometry and dimensions:

- R_0 (radius of the cylindrical space through which electrons pass within the XY-plane) = 5 mm
- L_0 (length of the Wien filter taken in the Z-axis direction) = 40 mm
- θ_0 (angle between lines passing through the centers of the gaps G_1 to G_{12} between the poles) = 30°
- $\delta\theta$ (lateral width of each gap) = 6°

[0048] The accelerating voltage was 2.5 kV. The following potentials and magnetomotive forces were applied by the method of the first embodiment (Figs. 3 and 4) to the poles P_1 to P_{12} , respectively:

$$V_1 = 1642.4243 \text{ V}$$

$$V_2 = 326.5973 \text{ V}$$

$$NI_1 = 44.0753 \text{ AT}$$

$$NI_2 = 8.7060 \text{ AT}$$

[0049] The dipole components E_1 and B_1 , quadrupole components E_2 and B_2 , and high-order inhomogeneous components E_3 and B_3 of the electric and magnetic fields, respectively, where the above-described potentials or magnetomotive forces were applied to the poles P_1 to P_{12} were numerically calculated by the boundary element method (BEM).

[0050] The dipole component E_1 and quadrupole component E_2 of the electric field where the potential V_1 for the dipole electric field was 1 V were as follows. (Note that each actual value is equal to each of the following values multiplied by 1642.4243.)

$$E_1 = 218.6 \text{ V/m}$$

$$E_2 = 43390 \text{ V/m}^2$$

[0051] Where the magnetomotive force NI_1 for the dipole magnetic field was 1 ampere-turn (AT), the dipole magnetic component B_1 and quadrupole magnetic component B_2 were as follows. (Note that each actual value is equal to each of the following values multiplied by 44.0753.)

$$B_1 = 0.0002748 \text{ T/m}$$

$$B_2 = 0.03142 \text{ T/m}^2$$

[0052] These fulfill the Wien's condition ($E_1 = v B_1$) and satisfy stigmatic focusing condition ($E_2/E_1 - B_2/B_1 = -1/4R$), where R is the cyclotron radius (mv^2/eE_1), where v is the velocity of electrons, m is the mass of each electron, and e is the charge of each electron.

[0053] Fig. 6 shows the intensity distribution of the high-order inhomogeneous component E_3 of the above-described electric field in the Z-axis direction in this embodiment. As can be seen by comparison of Fig. 6 with Fig. 8, the value of the high-order inhomogeneous component E_3 is reduced to about 10^{-4} compared with the octopole Wien filter. The high-order inhomogeneous component B_3 similarly decreases in a manner not illustrated.

[0054] In this embodiment, E_3 and B_3 assume very small values in this way. Accordingly, the aberration correction condition can be satisfied by setting the high-order inhomogeneous components E_3 and B_3 of the electric and magnetic fields to desired values.

[0055] In other words, the magnitudes of the inhomogeneous components E_3 and B_3 of the electric and magnetic fields can be reduced to about 10^{-4} by varying the number of poles of the Wien filter from 8 to 12. Therefore, aberration in the filter can be corrected.

[0056] Fig. 7 shows the configuration of an electron microscope incorporating a Wien filter according to the present invention. Fig. 7 (a) shows an embodiment in which the Wien filter according to the invention is placed between an FEG and an accelerator. A beam of electrons having relatively low energies of 1 keV to several kilovolts is produced by the FEG, 11, and enters a deceleration type energy filter 17 consisting of an entrance aperture 12, a deceleration portion 13, a Wien filter 14, an acceleration portion 15, and an exit aperture 16. In this deceleration type energy filter 17, the incident electrons are decelerated to energies of hundreds of eV by the deceleration portion and then only electrons having a given energy are selected by the Wien filter 14. The electrons are accelerated back to the original energies by the accelerating portion 15. Then, they exit from the exit aperture 16. The Wien filter 14 has the structure of the first embodiment (Figs. 3 and 4) or the second embodiment (Figs. 3 and 5).

[0057] The electron beam going out of the exit aperture 16 is accelerated to a desired high energy (e.g., about 200 keV) by an accelerator 18. Then, the beam is made to strike a sample 21 via condenser lenses 19 and an objective lens 20. A TEM image created by the electron beam transmitted through the sample 21 is then magnified by an intermediate lens (not shown) and a projector lens (not shown). The image is then projected onto a fluorescent screen (not shown) located behind the projector lens.

[0058] Fig. 7 (b) shows an embodiment in which a Wien filter according to the invention is placed behind an accelerator.

In this embodiment, a beam of electrons having relatively low energies of 1 keV to several kilovolts is produced by the FEG, 11, and then accelerated to a desired high energy (e.g., about 200 keV) by an accelerator 18. Then, the beam enters a deceleration type energy filter 17 via condenser lenses 22, the energy filter consisting of an entrance aperture 12, a deceleration portion 13, a Wien filter 14, an acceleration portion 15, and an exit aperture 16. In this deceleration type energy filter 17, the incident electrons are decelerated to energies of hundreds of eV by the deceleration portion and then only electrons having a given energy are selected by the Wien filter 14. The electrons are accelerated back to the original energies by the accelerating portion 15. Then, they exit from the exit aperture 16. The Wien filter 14 has the structure of the first embodiment (Figs. 3 and 4) or the second embodiment (Figs. 3 and 5).

[0059] The electron beam going out of the exit aperture 16 is made to strike a sample 21 via condenser lenses 19 and an objective lens 20. A TEM image created by the electron beam transmitted through the sample 21 is then magnified by an intermediate lens (not shown) and a projector lens (not shown). The image is then projected onto a fluorescent screen (not shown) located behind the projector lens.

[0060] In this embodiment of Fig. 7(b), the deceleration portion 13 and acceleration portion 15 of the deceleration type energy filter 17 need to accelerate high-energy electrons to hundreds of eV and to accelerate back to the original high energies. Therefore, multistage deceleration and multistage acceleration using multiple stages of electrodes are preferably employed in the same way as the original accelerator 18.

[0061] Where the above-described Wien filter according to the invention is used as an analyzer, the Wien filter may be positioned downstream of the sample, e.g., between the objective lens and the projector lens.

[0062] As described thus far, in the Wien filter according to the present invention, high-order inhomogeneous components of electric and magnetic fields can be made small. Aberration in the Wien filter can be reduced.

Claims

1. A Wien filter having an optical axis (O) substantially parallel to a Z-axis, the Wien filter producing at least a dipole electric field (E_1) in the direction of an X-axis and a dipole magnetic field (B_1) in the direction of a Y-axis, said Wien filter **characterised by** comprising:

12 poles (P_1 - P_{12}) extending substantially parallel to the optical axis in the direction of the Z-axis, said 12 poles having front ends (P_1' - P_{12}') facing the optical axis within an XY-plane, said front ends having a 12-fold rotational symmetry about the optical axis,

wherein two axes perpendicular to said optical axis are assumed to be the X- and Y-axes,

the Wien filter further comprising an electric potential application means arranged to apply a first electric potential (V_1) of positive or negative sign to four ones ($P_{1,6,7,12}$) of said 12 poles whose front ends ($P_{1,6,7,12}'$) are substantially parallel to the X-axis and also to four ones ($P_{2,5,8,11}$) of said 12 poles whose front ends ($P_{2,5,8,11}'$) are at an angle of 45° to the X-axis to produce the dipole electric field and to apply a second electric potential (V_2) of positive or negative sign to four ones ($P_{1,5,7,12}$) of said 12 poles (P_1 - P_{12}) whose front ends ($P_{1,6,7,12}'$) are substantially parallel to said X-axis and also to four ones ($P_{3,4,9,10}$) of said 12 poles whose front ends ($P_{3,4,9,10}'$) are substantially parallel to the Y-axis to superimpose a quadrupole electric field (E_2) on said dipole electric field (E_1), wherein the electric potential application means is arranged to apply the following potentials to the poles: V_1+V_2 to the first pole (P_1), V_1 to the second pole (P_2), $-V_2$ to the third pole (P_3), $-V_2$ to the fourth pole (P_4), $-V_1$ to the fifth pole (P_5), $-V_1+V_2$ to the sixth pole (P_6), $-V_1+V_2$ to the seventh pole (P_7), $-V_1$ to the eighth pole (P_8), $-V_2$ to the ninth pole (P_9), $-V_2$ to the tenth pole (P_{10}), V_1 to the eleventh pole (P_{11}), and V_1+V_2 to the twelfth pole (P_{12}), and

a magnetic potential application means arranged to apply a first magnetic potential or magnetomotive force (NI_1) of positive or negative sign to four ones ($P_{3,4,9,10}$) of said 12 poles whose front ends ($P_{3,4,9,10}'$) are substantially parallel to the Y-axis and also to four ones ($P_{2,5,8,11}$) of said 12 poles whose front ends ($P_{2,5,8,11}'$) are at an angle of 45° to the Y-axis to produce the dipole magnetic field and to apply a second magnetic potential or magnetomotive force (NI_2) of positive or negative sign to four ones ($P_{2,5,8,11}$) of said 12 poles (P_1 - P_{12}) whose front ends ($P_{2,5,8,11}'$) are each at an angle of about 45° to the X-axis or Y-axis to superimpose a quadrupole magnetic field (B_2) on said dipole magnetic field (B_1), wherein the magnetic potential application means is arranged to apply the following potentials to the poles: NI_1+NI_2 to the second pole (P_2), NI_1 to the third pole (P_3), NI_1 to the fourth pole (P_4), NI_1-NI_2 to the fifth pole (P_5), $-NI_1+NI_2$ to the eighth pole (P_8), $-NI_1$ to the ninth pole (P_9), $-NI_1$ to the tenth pole (P_{10}), and $-NI_1-NI_2$ to the eleventh pole (P_{11}).

2. The Wien filter of claim 1, wherein said front ends (P_1' - P_{12}') of said 12 poles (P_1 - P_{12}) are located on a circle that has a given radius (R_0) and is centered at the optical axis (O) within an XY-plane defined by said X- and Y-axes, and wherein the length of each of said front ends taken along said radius is comparable to or greater than the radius

of said circle.

3. The Wien filter of claim 1, wherein said 12 poles (P_1 - P_{12}) are made of a magnetic material.

4. An electron microscope comprising:

an electron gun (11) for producing an electron beam; and

a Wien filter (14) for passing only electrons having a certain energy, the Wien filter being in accordance with the Wien filter of any of claims 1 to 3,

the electron microscope being arranged such that, in use, an electron beam is made to strike a sample via the Wien filter.

Patentansprüche

1. Wienfilter, mit einer optischen Achse (O), die im Wesentlichen parallel zu einer Z-Achse verläuft, wobei der Wienfilter wenigstens ein elektrisches Dipolfeld (E_1) in Richtung einer X-Achse und ein magnetisches Dipolfeld (B_1) in Richtung einer Y-Achse erzeugt, wobei der Wienfilter **dadurch gekennzeichnet ist, dass** er Folgendes aufweist:

12 Pole (P_1 - P_{12}), die sich im Wesentlichen parallel zur optischen Achse in Richtung der Z-Achse erstrecken, wobei die 12 Pole vordere Enden (P_1' - P_{12}') aufweisen, die der optischen Achse innerhalb einer XY-Ebene zugewandt sind, wobei die vorderen Enden eine 12-fache Rotationssymmetrie um die optische Achse aufweisen, wobei zwei Achsen, die senkrecht zur optischen Achse sind, als X- und Y-Achsen betrachtet werden, wobei der Wienfilter ferner ein Anlagemittel für ein elektrisches Potenzial aufweist, das dazu ausgestaltet ist, ein erstes elektrisches Potenzial (V_1) mit positivem oder negativem Vorzeichen an vier Pole ($P_{1,6,7,12}$) der 12 Pole anzulegen, deren vordere Enden ($P_{1,6,7,12}'$) im Wesentlichen parallel zur X-Achse verlaufen, und auch an vier Pole ($P_{2,5,8,11}$) der 12 Pole, deren vordere Enden ($P_{2,5,8,11}'$) in einem Winkel von 45° zur X-Achse verlaufen, um das elektrische Dipolfeld zu erzeugen, und ein zweites elektrisches Potenzial (V_2) mit positivem oder negativem Vorzeichen an vier Pole ($P_{1,6,7,12}$) der 12 Pole (P_1 - P_{12}) anzulegen, deren vordere Enden ($P_{1,6,7,12}'$) im Wesentlichen parallel zur X-Achse verlaufen, und auch an vier Pole ($P_{3,4,9,10}$) der 12 Pole, deren vordere Enden ($P_{3,4,9,10}'$) im Wesentlichen parallel zur Y-Achse verlaufen, um ein vierpoliges elektrisches Feld (E_2) über das elektrische Dipolfeld (E_1) zu legen, wobei das Anlagemittel für ein elektrisches Potenzial dazu ausgestaltet ist, die folgenden Potenziale an die Pole anzulegen: V_1+V_2 an den ersten Pol (P_1), V_1 an den zweiten Pol (P_2), $-V_2$ an den dritten Pol (P_3), $-V_2$ an den vierten Pol (P_4), $-V_1$ an den fünften Pol (P_5), $-V_1+V_2$ an den sechsten Pol (P_6), $-V_1+V_2$ an den siebten Pol (P_7), $-V_1$ an den achten Pol (P_8), $-V_2$ an den neunten Pol (P_9), $-V_2$ an den zehnten Pol (P_{10}), V_1 an den elften Pol (P_{11}) und V_1+V_2 an den zwölften Pol (P_{12}), und wobei ein Anlagemittel für ein magnetisches Potenzial dazu ausgestaltet ist, ein erstes magnetisches Potenzial oder eine magnetomotorische Kraft (NI_1) mit positivem oder negativem Vorzeichen an vier Pole ($P_{3,4,9,10}$) der 12 Pole anzulegen, deren vordere Enden ($P_{3,4,9,10}'$) im Wesentlichen parallel zur Y-Achse verlaufen, und auch an vier Pole ($P_{2,5,8,11}$) der 12 Pole, deren vordere Enden ($P_{2,5,8,11}'$) in einem Winkel von 45° zur Y-Achse verlaufen, um das magnetische Dipolfeld zu erzeugen, und ein zweites magnetisches Potenzial oder eine magnetomotorische Kraft (NI_2) mit positivem oder negativem Vorzeichen an vier Pole ($P_{2,5,8,11}$) der 12 Pole (P_1 - P_{12}) anzulegen, deren vordere Enden ($P_{2,5,8,11}'$) jeweils in einem Winkel von ungefähr 45° zur X-Achse oder Y-Achse verlaufen, um ein vierpoliges magnetisches Feld (B_2) über das magnetische Dipolfeld (B_1) zu legen, wobei das Anlagemittel für ein magnetisches Potenzial dazu ausgestaltet ist, die folgenden Potenziale an die Pole anzulegen: NI_1+NI_2 an den zweiten Pol (P_2), NI_1 an den dritten Pol (P_3), NI_1 an den vierten Pol (P_4), NI_1-NI_2 an den fünften Pol (P_5), $-NI_1+NI_2$ an den achten Pol (P_8), $-NI_1$ an den neunten Pol (P_9), $-NI_1$ an den zehnten Pol (P_{10}) und $-NI_1-NI_2$ an den elften Pol (P_{11}).

2. Wienfilter nach Anspruch 1, wobei die vorderen Enden (P_1' - P_{12}') der 12 Pole (P_1 - P_{12}) auf einem Kreis angeordnet sind, der einen vorgegebenen Radius (R_0) aufweist und an der optischen Achse (O) innerhalb einer XY-Ebene zentriert ist, die von der X- und der Y-Achse definiert ist, und wobei die Länge eines jeden der vorderen Enden entlang des Radius vergleichbar mit oder größer als der Radius des Kreises ist.

3. Wienfilter nach Anspruch 1, wobei die 12 Pole (P_1 - P_{12}) aus einem magnetischen Material hergestellt sind.

4. Elektronenmikroskop, das Folgendes aufweist:

eine Elektronenkanone (11) zur Erzeugung eines Elektronenstrahls; und einen Wienfilter (14) zum Durchlassen lediglich von Elektronen, die eine bestimmte Energie aufweisen, wobei der Wienfilter dem Wienfilter nach einem der Ansprüche 1 bis 3 entspricht, wobei das Elektronenmikroskop so ausgestaltet ist, dass bei Verwendung ein Elektronenstrahl über den Wienfilter auf eine Probe auftreffen gelassen wird.

Revendications

1. Filtre de Wien ayant un axe optique (0) sensiblement parallèle à un axe Z, le filtre de Wien produisant au moins un champ électrique dipolaire (E_1) dans la direction d'un axe X et un champ magnétique dipolaire (B_1) dans la direction d'un axe Y, ledit filtre de Wien étant **caractérisé en ce qu'il** comprend :

12 pôles (P_1 à P_{12}) s'étendant sensiblement parallèlement à l'axe optique dans la direction de l'axe Z, lesdits 12 pôles ayant des extrémités avant (P_1' à P_{12}') en regard de l'axe optique dans un plan XY, lesdites extrémités avant ayant une symétrie de rotation de 12 fois autour de l'axe optique, dans lequel deux axes perpendiculaires audit axe optique sont supposés être les axes X et Y, le filtre de Wien comprenant en outre des moyens d'application de potentiel électrique agencés pour appliquer un premier potentiel électrique (V_1) de signe positif ou négatif à quatre ($P_{1,6,7,12}$) desdits 12 pôles dont les extrémités avant ($P_{1,6,7,12}'$) sont sensiblement parallèles à l'axe X, et également à quatre ($P_{2,5,8,11}$) desdits pôles 12 dont les extrémités avant ($P_{2,5,8,11}'$) sont à un angle de 45° par rapport à l'axe X pour produire le champ électrique de dipôle, et pour appliquer un second potentiel électrique (V_2) de signe positif ou négatif à quatre ($P_{1,6,7,12}$) desdits 12 pôles (P_1 à P_{12}) dont les extrémités avant ($P_{1,6,7,12}'$) sont sensiblement parallèles audit axe X, et également à quatre ($P_{3,4,9,10}$) desdits 12 pôles dont les extrémités avant ($P_{3,4,9,10}'$) sont sensiblement parallèles à l'axe Y pour superposer un champ électrique quadripolaire (B_2) sur ledit champ électrique dipolaire (E_1), dans lequel les moyens d'application de potentiel électrique sont agencés pour appliquer les potentiels suivants aux pôles : V_1+V_2 au premier pôle (P_1), V_1 au deuxième pôle (P_2), $-V_2$ au troisième pôle (P_3), $-V_2$ au quatrième pôle (P_4), $-V_1$ au cinquième pôle (P_5), $-V_1+V_2$ au sixième pôle (P_6), $-V_1+V_2$ au septième pôle (P_7), $-V_1$ au huitième pôle (P_8), $-V_2$ au neuvième pôle (P_9), $-V_2$ au dixième pôle (P_{10}), V_1 au onzième pôle (P_{11}) et V_1+V_2 au douzième pôle (P_{12}), et des moyens d'application de potentiel magnétique agencés pour appliquer un premier potentiel magnétique ou une première force magnétomotrice (NI_1) de signe positif ou négatif à quatre ($P_{3,4,9,10}$) desdits 12 pôles dont les extrémités avant ($P_{3,4,9,10}'$) sont sensiblement parallèles à l'axe Y, et également à quatre ($P_{2,5,8,11}$) desdits 12 pôles dont les extrémités avant ($P_{2,5,8,11}'$) sont à un angle de 45° par rapport à l'axe Y pour produire le champ magnétique dipolaire, et pour appliquer un second potentiel magnétique ou une seconde force magnétomotrice (NI_2) de signe positif ou négatif à quatre desdits 12 pôles (P_1 à P_{12}) dont les extrémités avant ($P_{2,5,8,11}'$) sont chacune sur un angle d'environ 45° par rapport à l'axe X ou l'axe Y pour superposer un champ magnétique quadripolaire (B_2) sur ledit champ magnétique dipolaire (B_1), dans lequel les moyens d'application de potentiel magnétique sont agencés pour appliquer les potentiels suivants aux pôles : NI_1+NI_2 au deuxième pôle (P_2), NI_1 au troisième pôle (P_3), NI_1 au quatrième pôle (P_4), NI_1-NI_2 au cinquième pôle (P_5), $-NI_1+NI_2$ au huitième pôle (P_8), $-NI_1$ au neuvième pôle (P_9), $-NI_1$ au dixième pôle (P_{10}) et $-NI_1-NI_2$ au onzième pôle (P_{11}).

2. Filtre de Wien selon la revendication 1, dans lequel lesdites extrémités avant (P_1' à P_{12}') desdits 12 pôles (P_1 à P_{12}) sont situées sur un cercle ayant un rayon donné (R_0), et qui est centré sur l'axe optique (0) dans un plan XY défini par lesdits axes X et Y, et dans lequel la longueur de chacune desdites extrémités avant prise le long dudit rayon est comparable ou supérieure au rayon dudit cercle.

3. Filtre de Wien selon la revendication 1, dans lequel lesdits 12 pôles (P_1 à P_{12}) sont constitués d'un matériau magnétique.

4. Microscope électronique, comprenant :

un canon à électrons (11) pour produire un faisceau d'électrons ; et un filtre de Wien (14) pour ne laisser passer que des électrons ayant une certaine énergie, le filtre de Wien étant en conformité avec le filtre de Wien de l'une quelconque des revendications 1 à 3, le microscope électronique étant agencé de telle sorte qu'en utilisation, un faisceau d'électrons est réalisé pour frapper un échantillon via le filtre de Wien.

Fig. 1

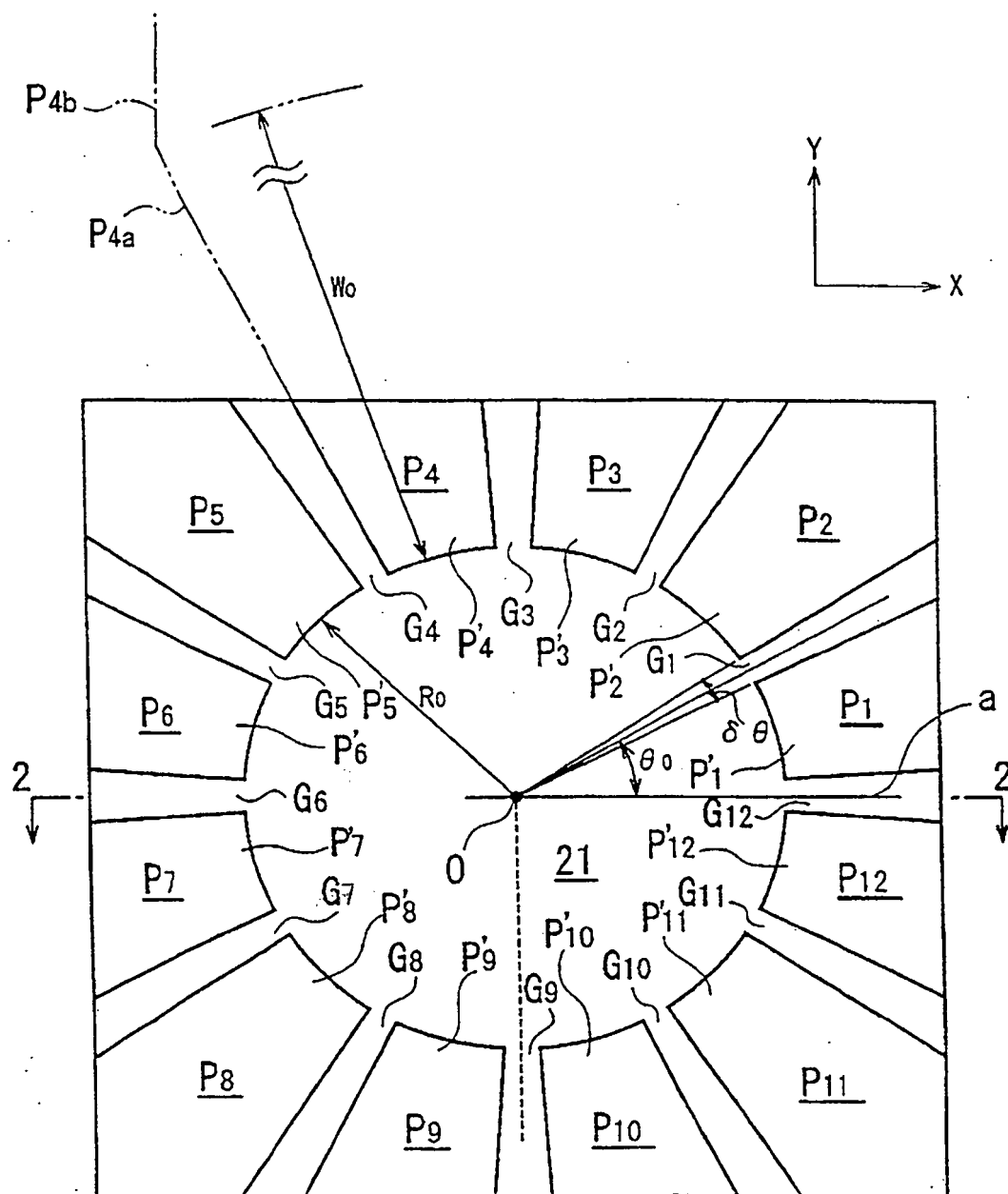


Fig. 2

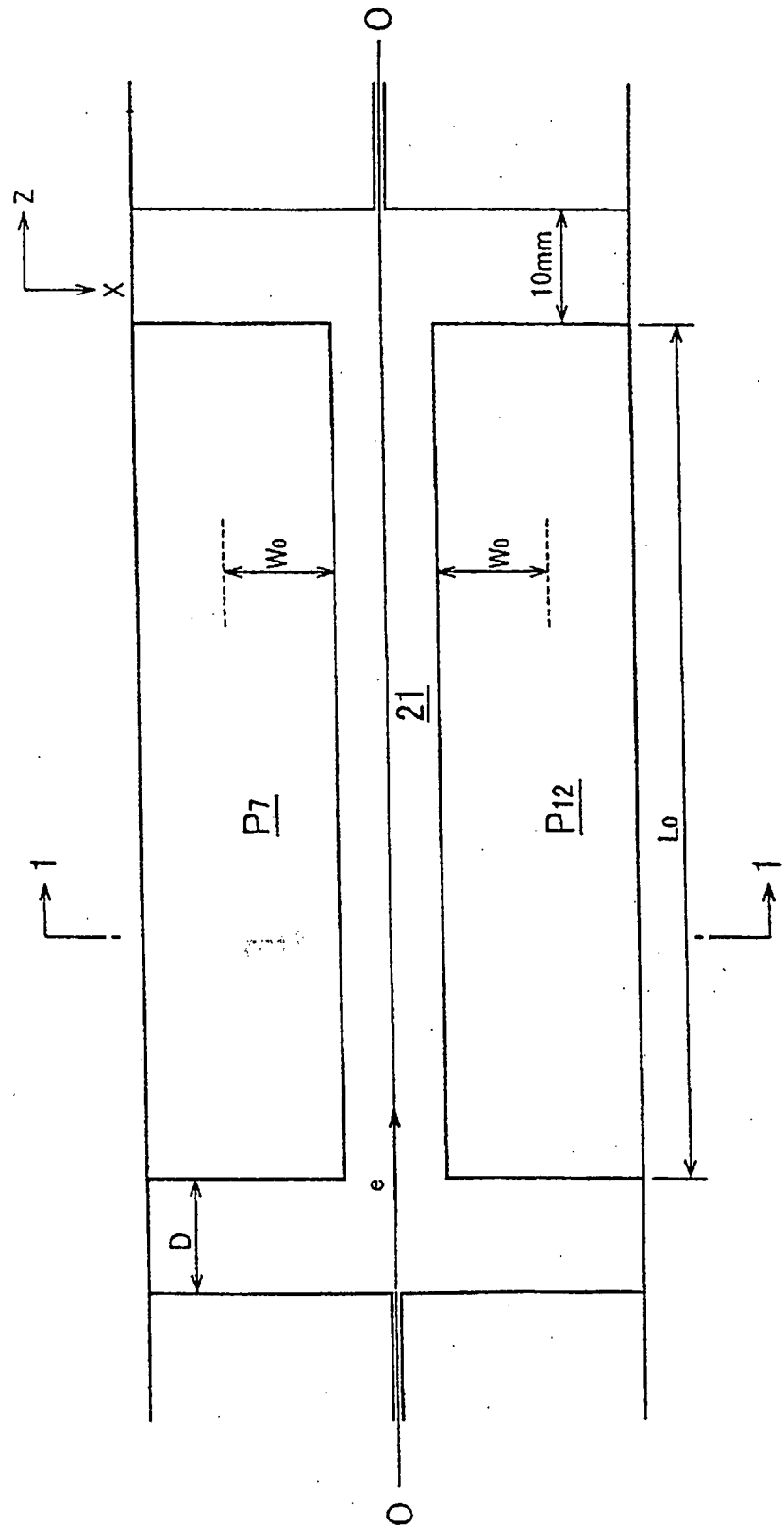


Fig. 3

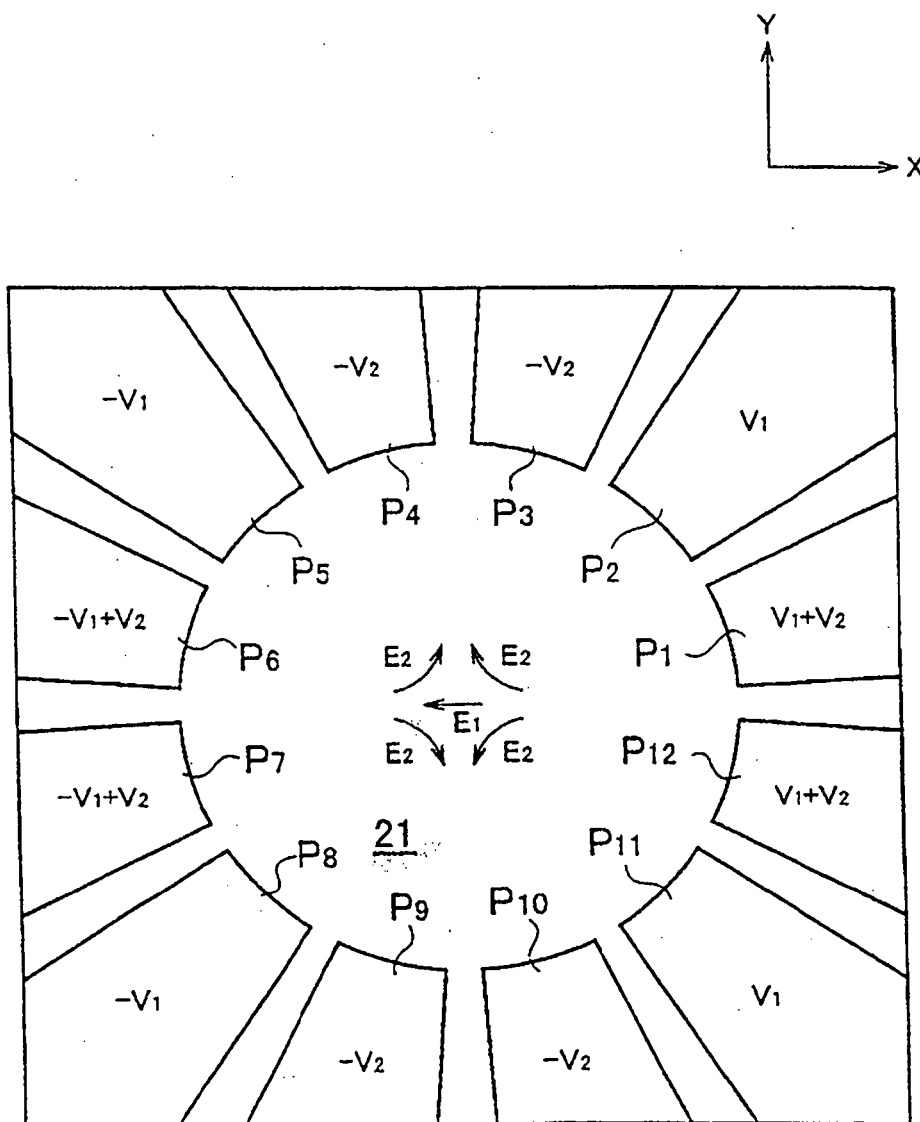


Fig. 4

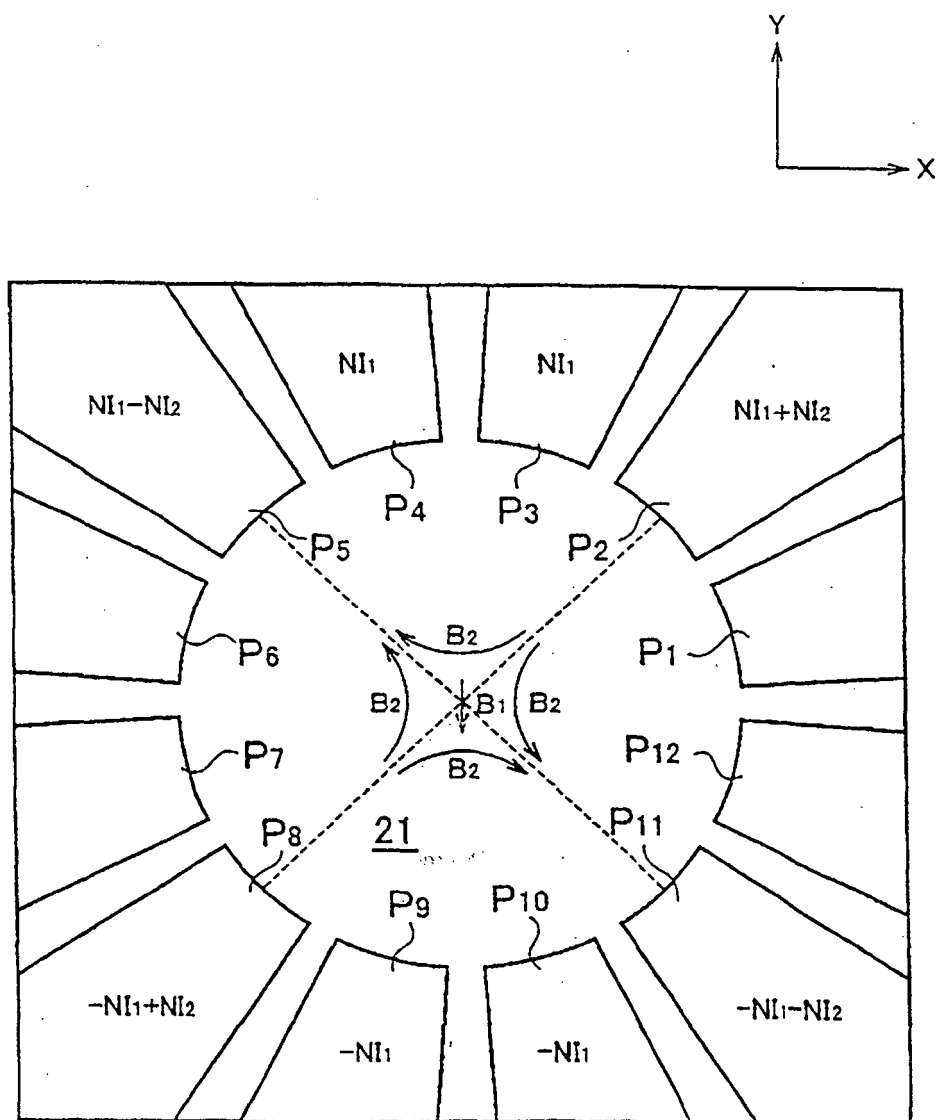


Fig. 5

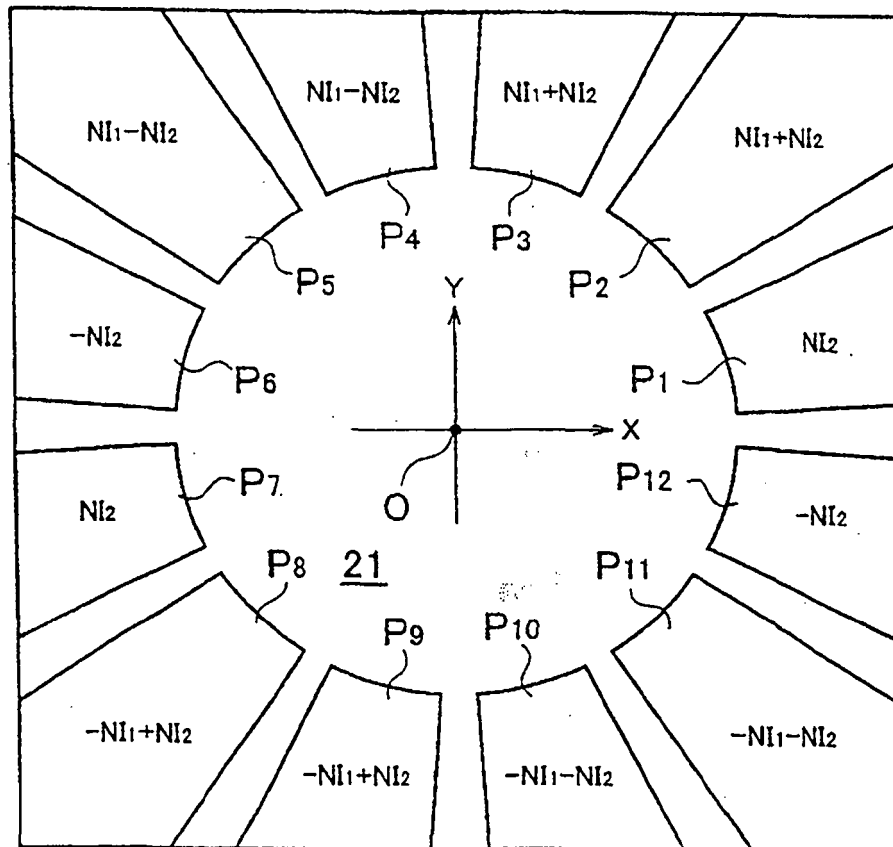
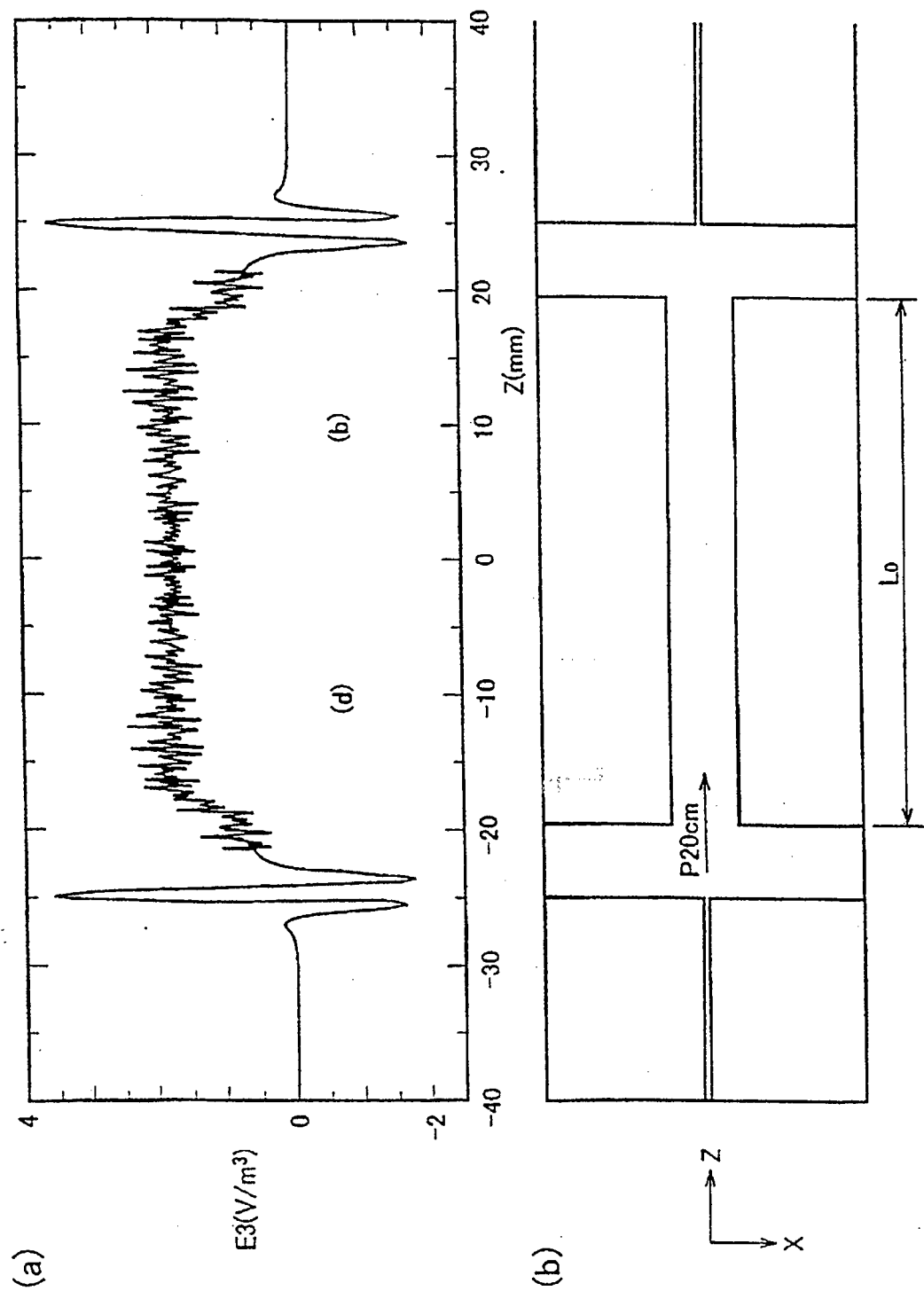


Fig. 6



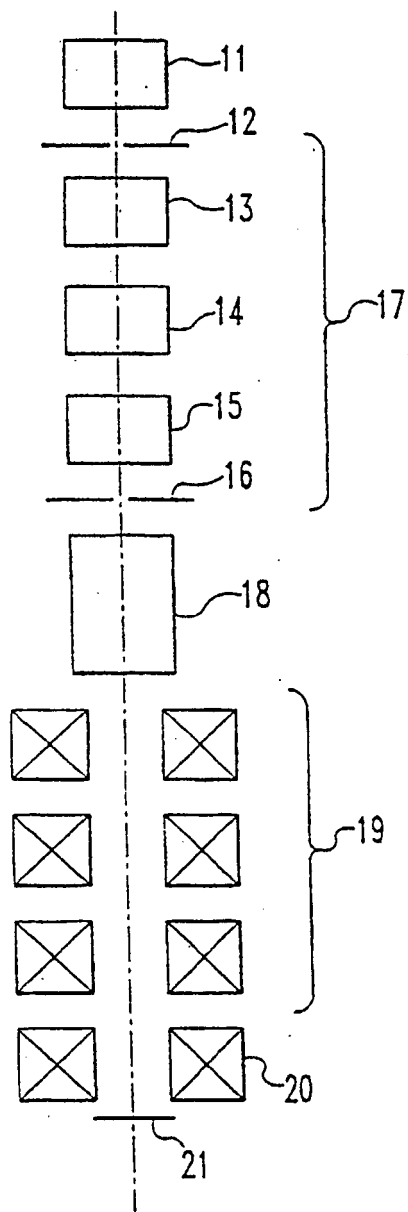


FIG. 7(a)

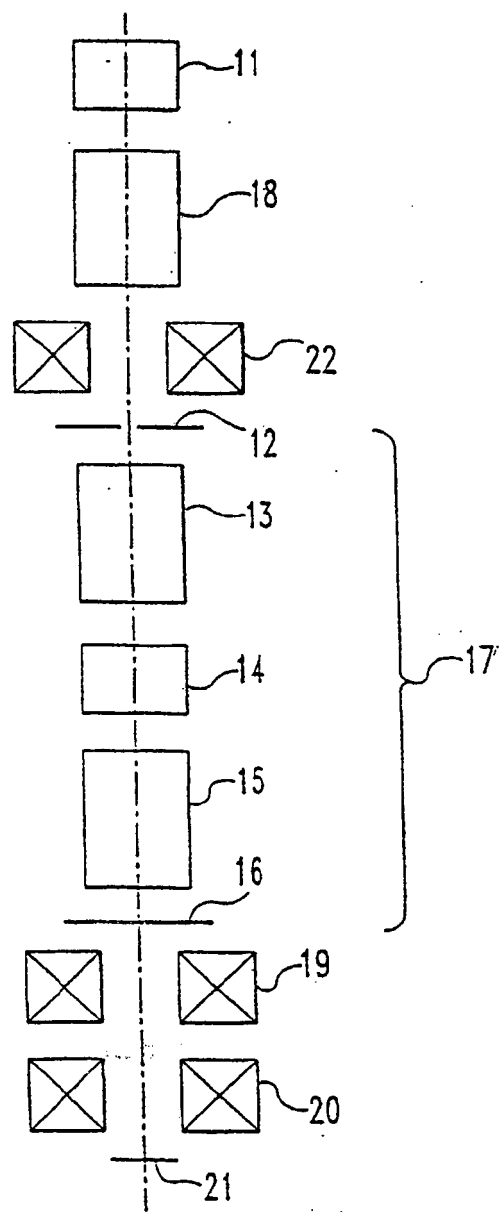


FIG. 7(b)

Fig. 8

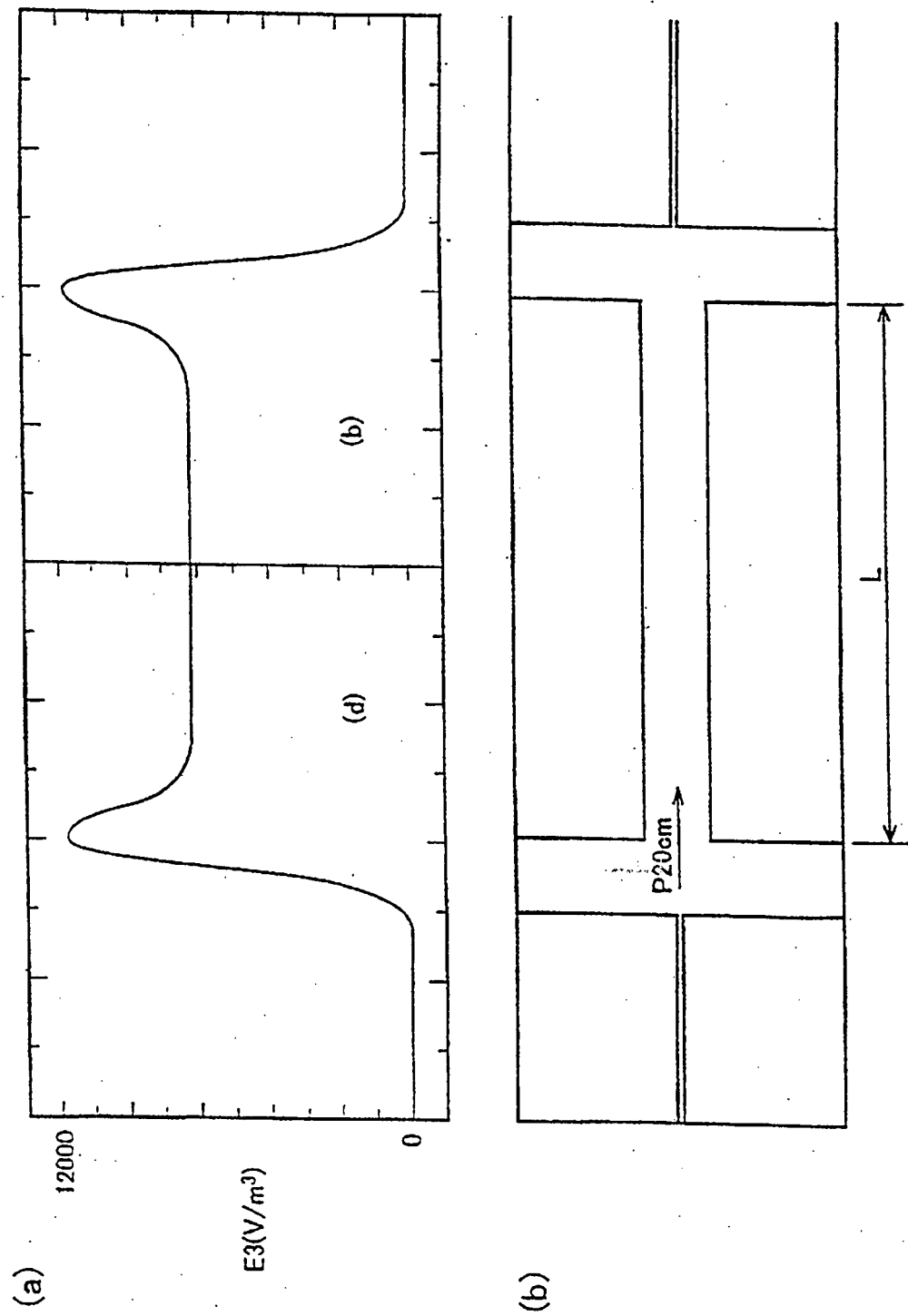
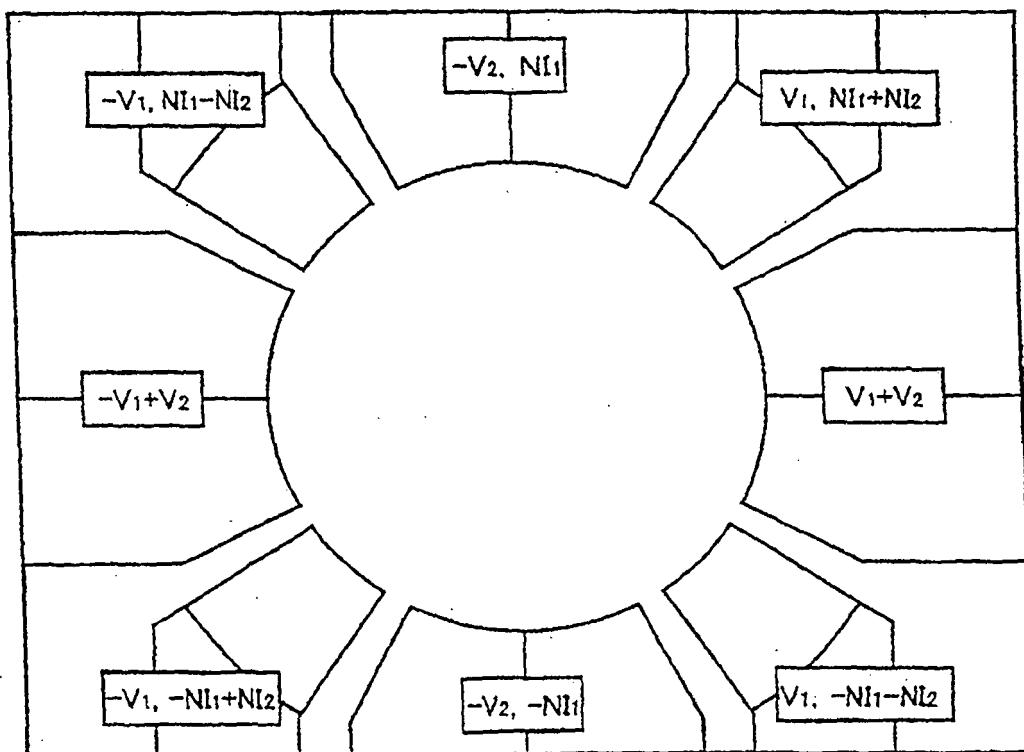
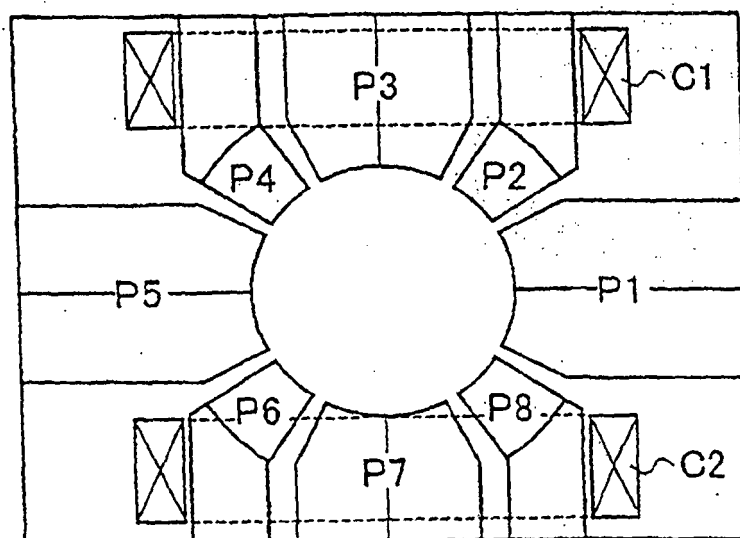


Fig: 9

(a)



(b)



REFERENCES CITED IN THE DESCRIPTION

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